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| APPLICATION NO. | FILING DATE | FIRST NAMED INVENTOR | ATTORNEY DOCKET NO. | CONFIRMATION NO. | |
|-----------------|--------------------------------|----------------------|-------------------------|-----------------------|--|
| 09/939,073 | 08/24/2001 | Suketu Parikh | 5865/CALB/COPPER | 5865/CALB/COPPER 4234 | |
| 32588 | 7590 11/19/2002 | 4 | | | |
| APPLIED M | ATERIALS, INC. | EXAMINER | | | |
| | BLVD. M/S 2061 RA, CA 95050 | | WONG, | WONG, EDNA | |
| | | | ART UNIT | PAPER NUMBER | |
| | | | 1741 | 6 | |
| | | | DATE MAILED: 11/19/2002 | \mathcal{D} | |

Please find below and/or attached an Office communication concerning this application or proceeding.

| | | I | | <i>#</i> +>^ | | | |
|---|---|---|---|--------------|--|--|--|
| Office Action Summan | | Application No. | Applicant(s) | | | | |
| | | 09/939,073 | PARIKH ET AL. | | | | |
| | Office Action Summary | Examin r | Art Unit | | | | |
| | | Edna Wong | 1741 | | | | |
| Period to | Th MAILING DATE of this communication app ars on the coversh twith the correspondence address Period for Reply | | | | | | |
| THE N - Exter after: - If the - If NO - Failui - Any re | ORTENED STATUTORY PERIOD FOR REPLY MAILING DATE OF THIS COMMUNICATION. Issions of time may be available under the provisions of 37 CFR 1.13 SIX (6) MONTHS from the mailing date of this communication. period for reply specified above is less than thirty (30) days, a reply period for reply is specified above, the maximum statutory period we to reply within the set or extended period for reply will, by statute, apply received by the Office later than three months after the mailing dipatent term adjustment. See 37 CFR 1.704(b). | 36(a). In no event, however, may a reply be time within the statutory minimum of thirty (30) day ill apply and will expire SIX (6) MONTHS from Cause the application to become ABANDONE | nely filed s will be considered timely. the mailing date of this comm 0.035.U.S.C. 8.1233 | unication. | | | |
| 1) | Responsive to communication(s) filed on | <u></u> • | | | | | |
| 2a) | This action is FINAL . 2b)⊠ Thi | s action is non-final. | | | | | |
| 3) Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under <i>Ex parte Quayle</i> , 1935 C.D. 11, 453 O.G. 213. Disposition of Claims | | | | | | | |
| | Claim(s) <u>1-21</u> is/are pending in the application. | | | | | | |
| | a) Of the above claim(s) is/are withdraw | • | | | | | |
| 5) Claim(s) is/are allowed. | | | | | | | |
| | Claim(s) is/are rejected. | | | | | | |
| | Claim(s) is/are objected to. | | | | | | |
| 8) Claim(s) 1-21 are subject to restriction and/or election requirement. | | | | | | | |
| Application | | | | | | | |
| 9)∐ T | he specification is objected to by the Examiner. | | | | | | |
| 10) ☐ The drawing(s) filed on is/are: a) ☐ accepted or b) ☐ objected to by the Examiner. | | | | | | | |
| Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a). | | | | | | | |
| 11) 🗌 T | he proposed drawing correction filed on | is: a)☐ approved b)☐ disappro | ved by the Examiner. | | | | |
| | If approved, corrected drawings are required in repl | y to this Office action. | | | | | |
| 12) ☐ The oath or declaration is objected to by the Examiner. | | | | | | | |
| Priority ur | nder 35 U.S.C. §§ 119 and 120 | | | | | | |
| 13) 🗌 📝 | Acknowledgment is made of a claim for foreign | priority under 35 U.S.C. § 119(a) | -(d) or (f). | | | | |
| a)[|] All b) ☐ Some * c) ☐ None of: | | | | | | |
| 1 | . Certified copies of the priority documents | have been received. | | | | | |
| 2 | 2. Certified copies of the priority documents | have been received in Application | on No | | | | |
| | 3. Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)). | | | | | | |
| * See the attached detailed Office action for a list of the certified copies not received. | | | | | | | |
| 14) Acknowledgment is made of a claim for domestic priority under 35 U.S.C. § 119(e) (to a provisional application). | | | | | | | |
| 15)∏ Ad | ☐ The translation of the foreign language provice the translation of the foreign language provice. The translation of the tran | isional application has been rece priority under 35 U.S.C. §§ 120 | ived. and/or 121. | | | | |
| Attachment(: | | | | | | | |
| 2) D Notice | of References Cited (PTO-892) of Draftsperson's Patent Drawing Review (PTO-948) Ition Disclosure Statement(s) (PTO-1449) Paper No(s) | 5) Notice of Informal Pa | (PTO-413) Paper No(s) atent Application (PTO-152 | | | | |

Application/Control Number: 09/939,073

Art Unit: 1741

Page 2

Election/Restrictions

Restriction to one of the following inventions is required under 35 U.S.C. 121:

- Claims 1-15, drawn to a method of monitoring and controlling manufacturing processes within a multi-step manufacturing system having independently operating tools that perform specific processes upon a workpiece, classified in class 205, subclass 84.
- II. Claims 16 and 17, drawn to a method of monitoring and controlling copper interconnect manufacturing processes within a multi-step copper interconnect manufacturing system having independently operating tools that perform specific processes upon a semiconductor wafer, classified in class 205, subclass 157.
- III. Claims 18-21, drawn to apparatus for monitoring and controlling a multistep semiconductor wafer processing system, classified in class 204, subclass 228.7.

The inventions are distinct, each from the other because of the following reasons: Inventions I and II are related as combination and subcombination. Inventions in this relationship are distinct if it can be shown that (1) the combination as claimed does not require the particulars of the subcombination as claimed for patentability, and (2) that the subcombination has utility by itself or in other combinations (MPEP § 806.05(c)). In the instant case, the combination as claimed does not require the particulars of the subcombination as claimed because:

Group I is directed to a method that does not require depositing a barrier layer and a seed layer within a trench formed in a semiconductor wafer and performing electrochemical plating to deposit a copper layer upon the barrier and seed layer.

Group II is directed to a method that does require depositing a barrier layer and a seed layer within a trench formed in a semiconductor wafer and performing electrochemical plating to deposit a copper layer upon the barrier and seed layer.

The subcombination has separate utility by itself or in other combinations.

Inventions I-II and III are related as process and apparatus for its practice. The inventions are distinct if it can be shown that either: (1) the process as claimed can be practiced by another materially different apparatus or by hand, or (2) the apparatus as claimed can be used to practice another and materially different process. (MPEP § 806.05(e)). In this case the process as claimed can be practiced by another materially different apparatus such as a process where film thickness measurements can be taken at discrete times during the processing cycle without removing the wafer from the cluster tool as taught by Labunsky et al. (US Patent No. 6,132,289).

Because these inventions are distinct for the reasons given above and have acquired a separate status in the art as shown by their different classification, restriction for examination purposes as indicated is proper.

Because these inventions are distinct for the reasons given above and have

Application/Control Number: 09/939,073

Art Unit: 1741

acquired a separate status in the art because of their recognized divergent subject matter, restriction for examination purposes as indicated is proper.

A telephone call was made to Robert W. Mulcahy on November 15, 2002 to request an oral election to the above restriction requirement, but did not result in an election being made.

Applicant is advised that the reply to this requirement to be complete must include an election of the invention to be examined even though the requirement be traversed (37 CFR 1.143).

Applicant is reminded that upon the cancellation of claims to a non-elected invention, the inventorship must be amended in compliance with 37 CFR 1.48(b) if one or more of the currently named inventors is no longer an inventor of at least one claim remaining in the application. Any amendment of inventorship must be accompanied by a request under 37 CFR 1.48(b) and by the fee required under 37 CFR 1.17(i).

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Edna Wong whose telephone number is (703) 308-3818. The examiner can normally be reached on Mon-Fri 7:30 am to 5:00 pm, alt. Fridays off.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's

Art Unit: 1741

supervisor, Nam Nguyen can be reached on (703) 308-3322. The fax phone numbers for the organization where this application or proceeding is assigned are (703) 872-9310 for regular communications and (703) 873-9311 for After Final communications.

Any inquiry of a general nature or relating to the status of this application or proceeding should be directed to the receptionist whose telephone number is (703) 308-0661.

Primary Examiner

Art Unit 1741

EW November 15, 2002